

## WEST Search History

DATE: Friday, August 15, 2003

**Set Name Query**

side by side

**Hit Count Set Name**

result set

*DB=USPT,PGPB,JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ*

L5	L4 and l1	10	L5
L4	L2 same (substrate or wafer or semiconductor)	61	L4
L3	L2 and l1	109	L3
L2	(clean\$3 or etch\$3 or wash\$3 or rins\$3) same nozzle\$3 same transvers\$3	1928	L2
L1	((134/21  134/34  134/36  134/37  134/902  134/94.1  134/99.1  134/103.2  134/172  134/198 )!.CCLS.  (216/92 )!.CCLS.  (438/906 )!.CCLS.  (156/345.15  156/345.54  156/345.11  156/345.17  156/345.21  156/345.23 )!.CCLS. )	7818	L1

END OF SEARCH HISTORY